

Accepted Article Preview: Published ahead of advance online publication



## X-photon 3D lithography by fs-oscillators: wavelength-independent and photoinitiator-free

Dimitra Ladika, Antanas Butkus, Vasileia Melissinaki, Edvinas Skliutas, Elmina Kabouraki, Saulius Juodkazis, Maria Farsari, and Mangirdas Malinauskas

Cite this article as: Dimitra Ladika, *et.al.* X-photon 3D lithography by fs-oscillators: wavelength-independent and photoinitiator-free. *Light: Advanced Manufacturing* accepted article preview 27 August 2024; doi: 10.37188/lam.2024.044

This is a PDF file of an unedited peer-reviewed manuscript that has been accepted for publication. LAM are providing this early version of the manuscript as a service to our customers. The manuscript will undergo copyediting, typesetting and a proof review before it is published in its final form. Please note that during the production process errors may be discovered which could affect the content, and all legal disclaimers apply.

Received 5 December 2023; Revised 23 August 2024; Accepted 26 August 2024;  
Accepted article preview online 27 August 2024